

Application/Control No.	Applicant(s)/Patent under Reexamination	r
10/567,319	SNEH, OFER	
Examiner	Art Unit	
Rudy Zervigon	1792	

	SEARCHED				
Class	Subclass	Date	Examiner		
118	719	10/26/2009	RZ		
118	729	10/26/2009	RZ		
118	729	10/26/2009	RZ		
118	733	10/26/2009	RZ		
156	345.31	10/26/2009	RZ		
156	345.32	10/26/2009	RZ		
156	345.33	10/26/2009	RZ		
156	345.34	10/26/2009	RZ		

INTERFERENCE SEARCHED					
Class	Subclass	Date	Examiner		
118	719	10/26/2009	RZ		
118	729	10/26/2009	RZ		
156	345.31	10/26/2009	RZ		

SEARCH NOTES (INCLUDING SEARCH STRATEGY)		
	DATE	EXMR
SNEH-OFER.in. or SUNDEW- TECHNOLOGIES.asn.	10/26/2009	RZ
((inner and outer) with (chamber or reactor or vessel)).clm. or (liner with (chamber or reactor or vessel)).clm. and seal.clm	10/26/2009	RZ
and (wafer or substrate).clm.	10/26/2009	RZ